

Electronic Supplementary Information

Rationally Designed Ta₃N₅@ReS₂ Heterojunctions for Promoted Photocatalytic Hydrogen Production

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Chemicals:

Tantalum(V) chloride (TaCl_5 , A.R., Aladdin), glucose (Hushi), ammonium perrhenate (NH_4ReO_4 , A.R., Aladdin), thiourea ($\text{CH}_4\text{N}_2\text{S}$, AR, Hushi, China), hydroxylamine hydrochloride (HONH_3Cl , A.R., Aladdin), Sodium sulfide (Na_2S , A.R., Aladdin), sodium sulfate (Na_2SO_3 , AR, Hushi), Nafion perfluorinated resin solution (AR, Sigma-aldrich), ethanol ($\text{C}_2\text{H}_6\text{O}$, AR, Aladdin), and deionized water (Millipore, $18.2 \text{ M}\Omega\cdot\text{cm}$) was used as chemical reagents without further purification.

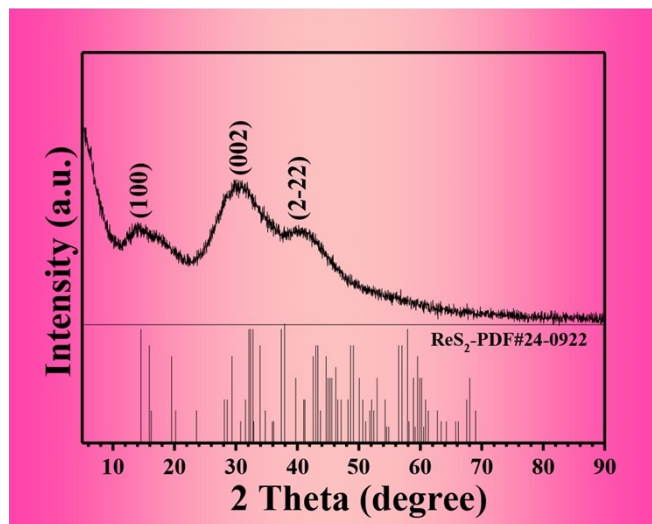


Fig. S1 XRD pattern of pure ReS₂.

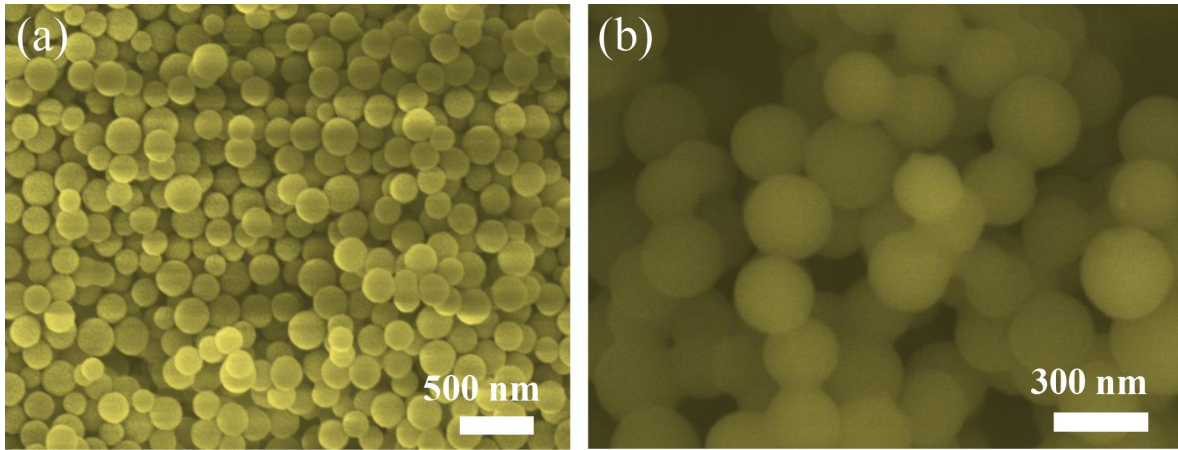


Fig. S2 (a-b) Typical SEM images of the used C balls

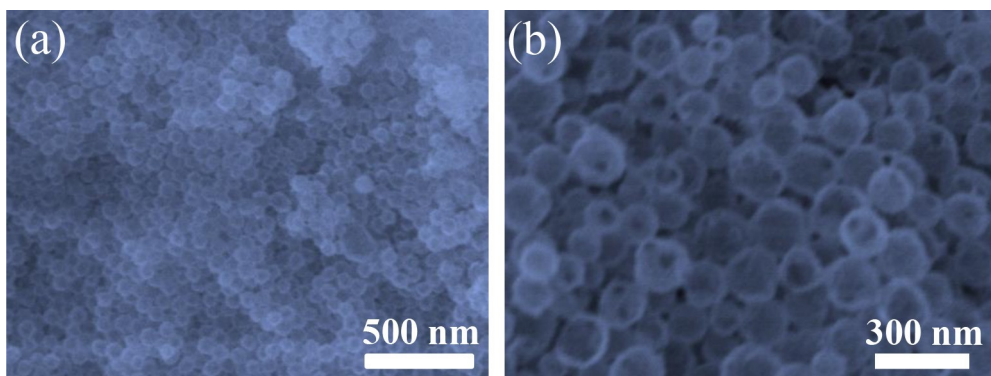


Fig. S3 (a-b) Typical SEM images of TaOx

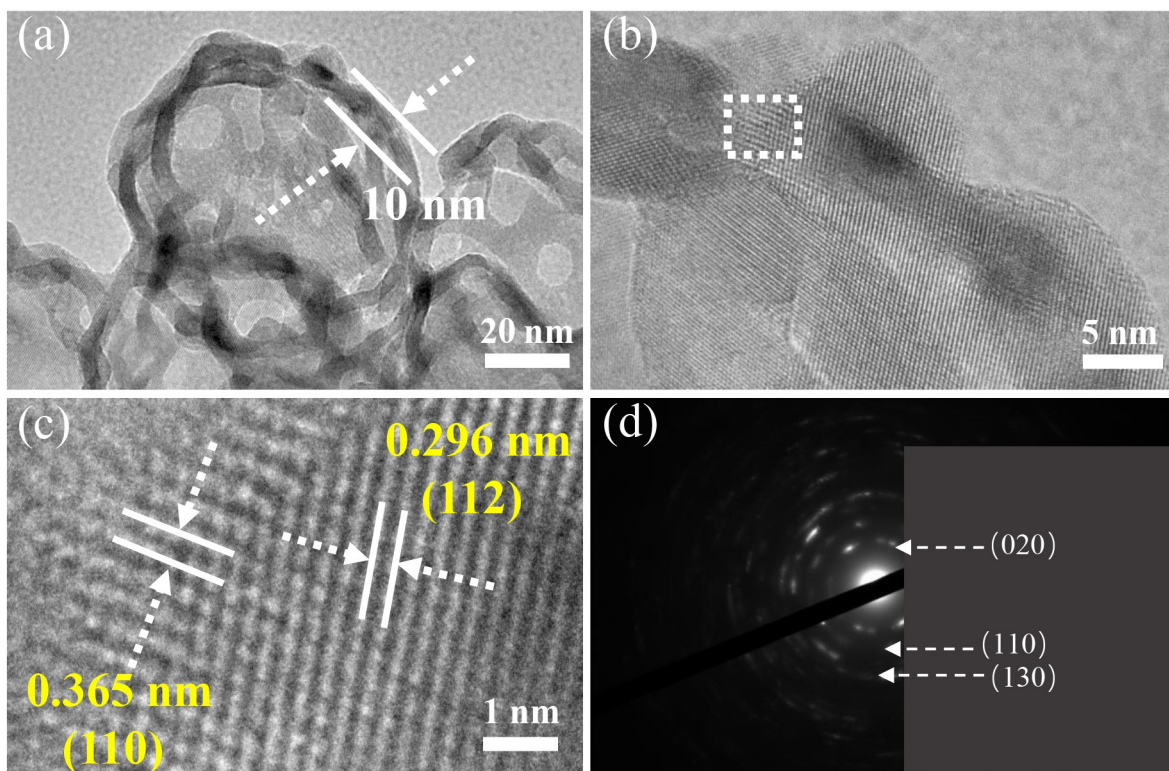


Fig. S4 TEM images (a-b), HRTEM image (c) and SAED pattern (d) of TR0.

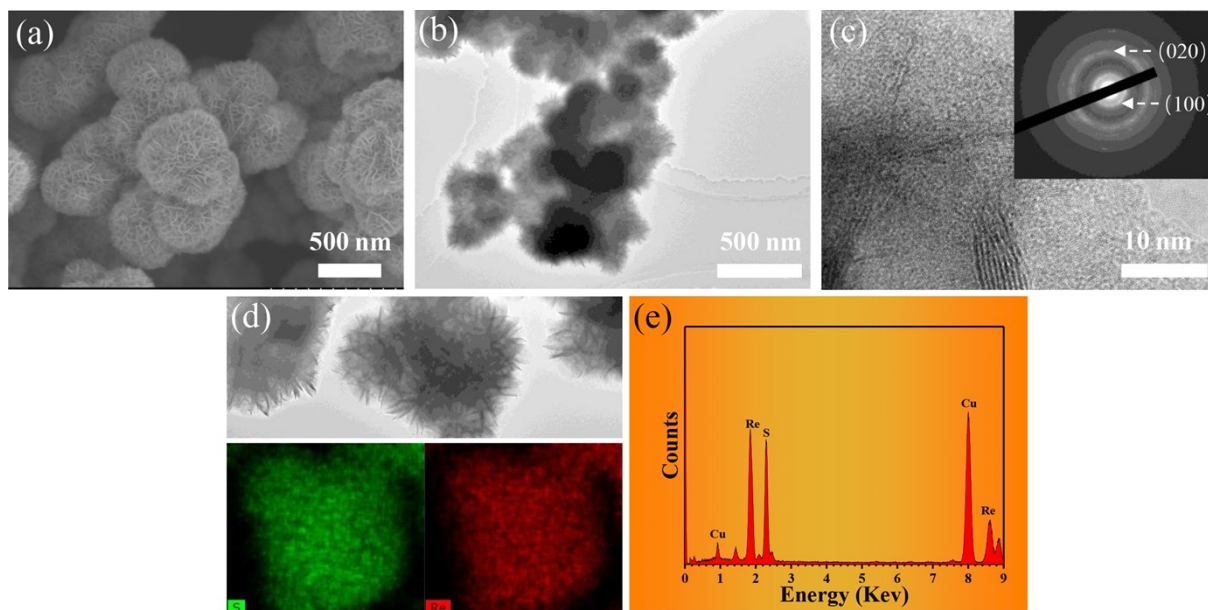


Fig. S5 TEM images (a-b) and HRTEM image (c) of ReS_2 , corresponding elemental mapping images (d), and EDX spectrum (e) of ReS_2 .

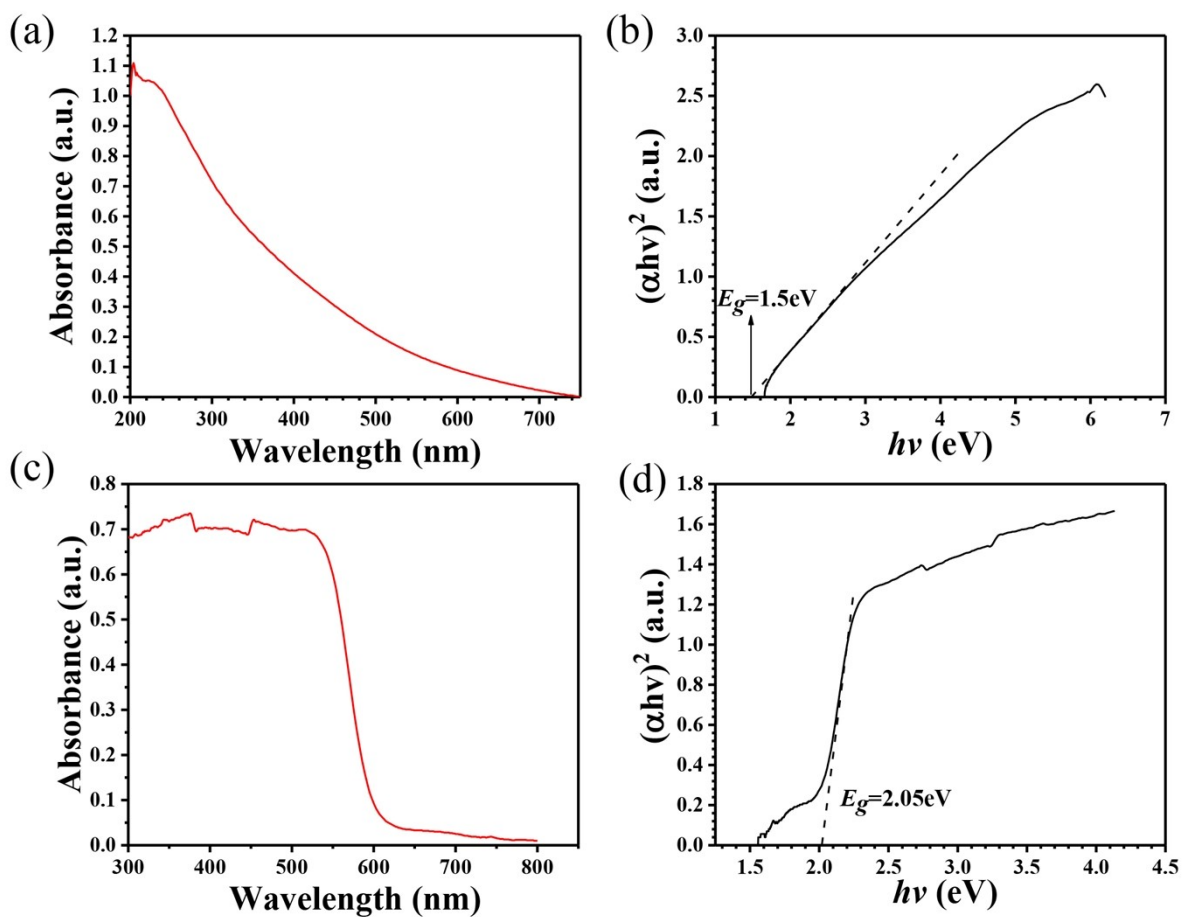


Fig. S6 (a-b) UV-visible absorption spectrum (a) and the calculated bandgap of ReS₂ (b), respectively. (c-d) UV-visible absorption spectrum (c) and the calculated bandgap of TR0 (d), respectively.

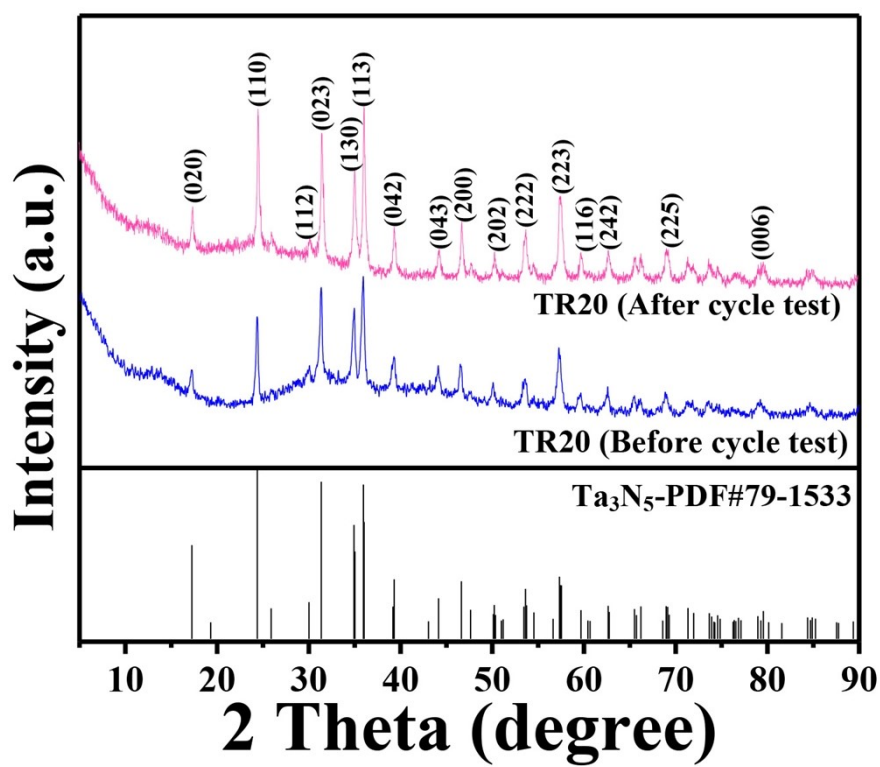


Fig. S7 XRD patterns of TR20 sample before and after cycle test.

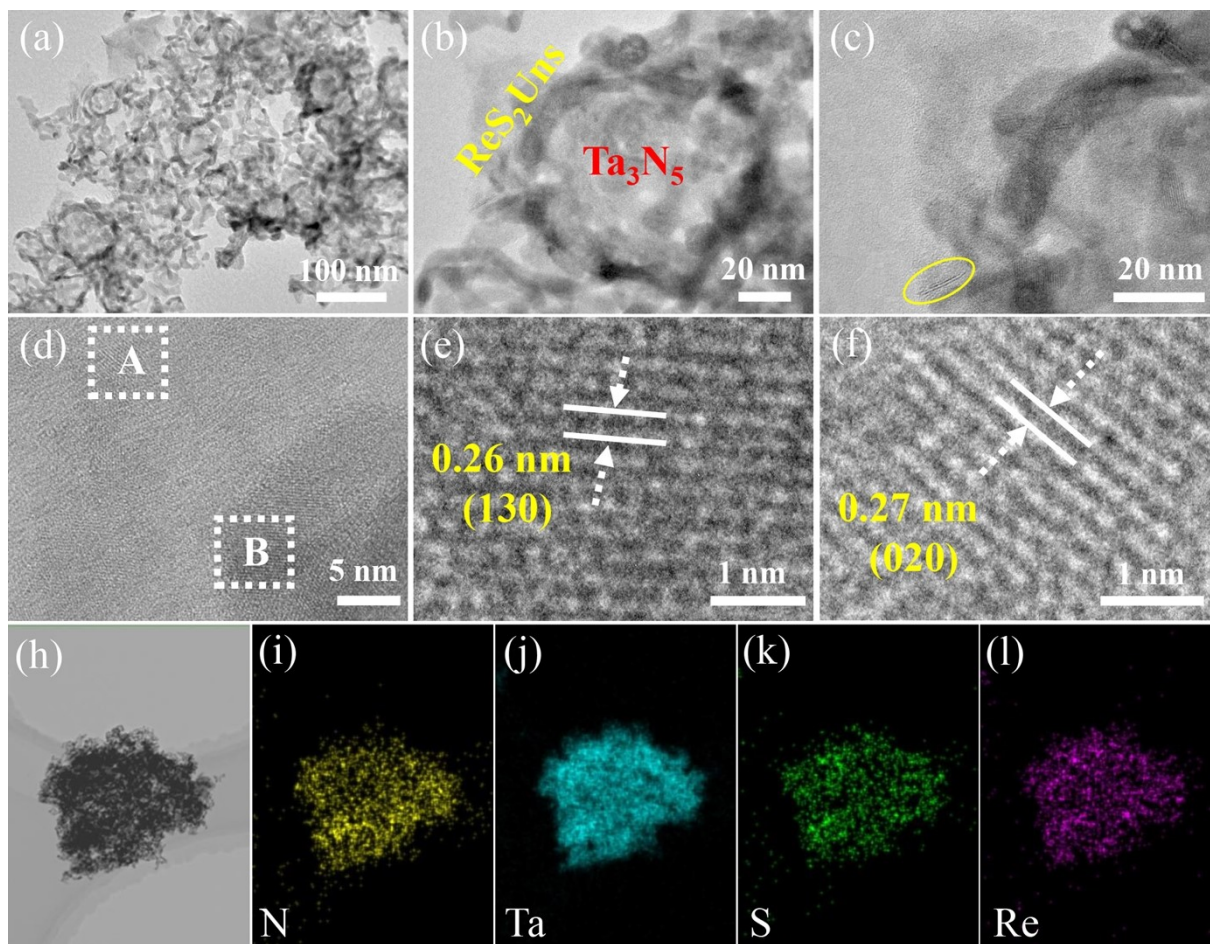


Fig. S8 TEM images (a-c), HRTEM images (d-f) and element mapping images (h-l) of TR20 sample after cycle test.

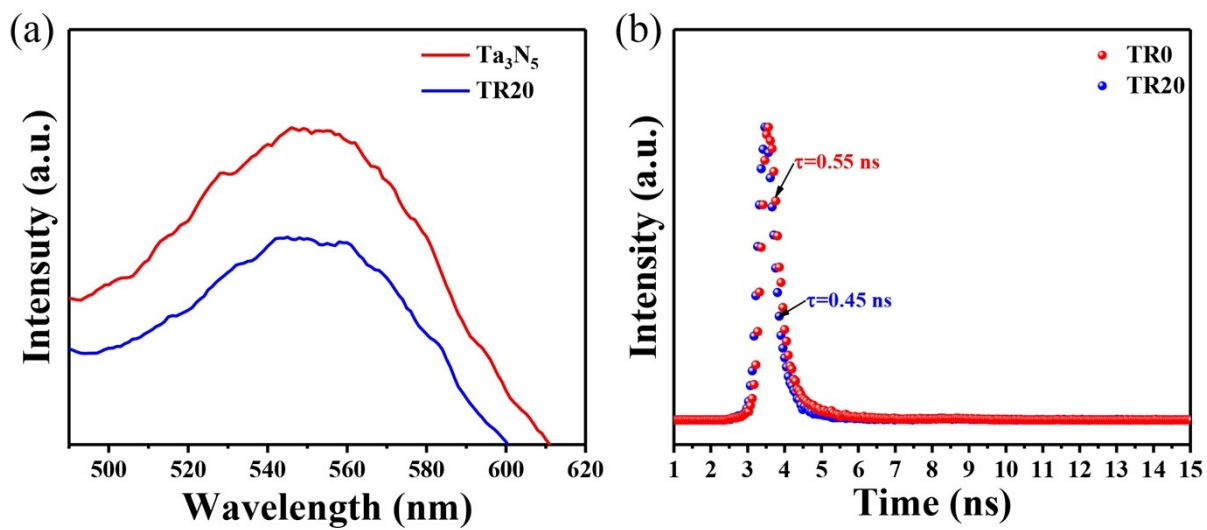


Fig. S9 (a-b) Steady state (a) and time-resolved (b) photoluminescence spectra of TR20, respectively.

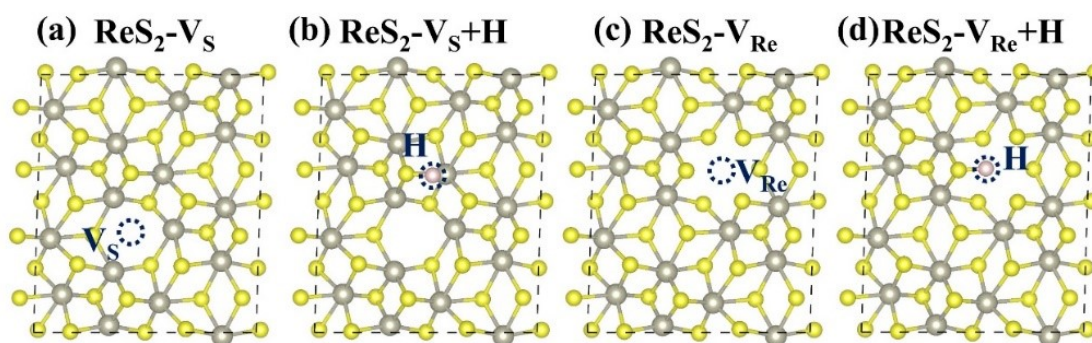


Fig. S10 (a, c) The optimized ReS_2 with S vacancy (V_S) (a) and Re vacancy (V_{Re}) (c), and (b, d) the corresponding H^* adsorption around defects, respectively.

Discussion:

An exploration on the impact of defects on HER performance is investigated by DFT. Because H^* is adsorbed on the surface of ReS_2 , in order to exclude the influence of adsorption sites, we mainly compare the effect of defects between sole ReS_2 systems and $\text{Ta}_3\text{N}_5@/\text{ReS}_2$ heterostructures with the H^* adsorbed at the same sites. As show in Fig. S10a-d, some surface defects, *e.g.*, S vacancy (V_S) and Re vacancy (V_{Re}), are built in ReS_2 surface and $\text{Ta}_3\text{N}_5@/\text{ReS}_2$ heterostructure, where the H^* is absorbed at hollow site of among three S atoms closest to the defects. The results show that V_S could hardly improve the HER performance of $\text{Ta}_3\text{N}_5@/\text{ReS}_2$ heterostructure, or even weaken that of ReS_2 surface (see Fig. 9f). In contrast, V_{Re} can significantly enhance the adsorption of H^* , leading to a much smaller ΔG_{H^*} (0.14 for $\text{ReS}_2-V_{\text{Re}}$ and 0.06 for $\text{Ta}_3\text{N}_5@/\text{ReS}_2-V_{\text{Re}}$) close to zero with enhanced HER performance. Owing to the higher electronegativity of S (2.58) than that of Re (1.90), the H^* trends to be adsorbed with S atom. Besides, the appearance of one V_{Re} will inevitably break six Re-S bonds (Fig. S10c), which leads to the dangling bonds of S atoms with unpaired electron that could attract H^* for electron pairing. Therefore, the V_{Re} brings an improved HER activity of ReS_2 -based materials. What's more, the combination of Ta_3N_5 in the $\text{Ta}_3\text{N}_5@/\text{ReS}_2$ systems could enhance the HER performance of sole ReS_2 , regardless of the existed defects. Especially, $\text{Ta}_3\text{N}_5@/\text{ReS}_2-V_{\text{Re}}$

exhibit better HER performance than both Ta_3N_5 and $\text{ReS}_2\text{-V}_{\text{Re}}$, representing the synergistic enhancement effect of Ta_3N_5 , ReS_2 and V_{Re} .

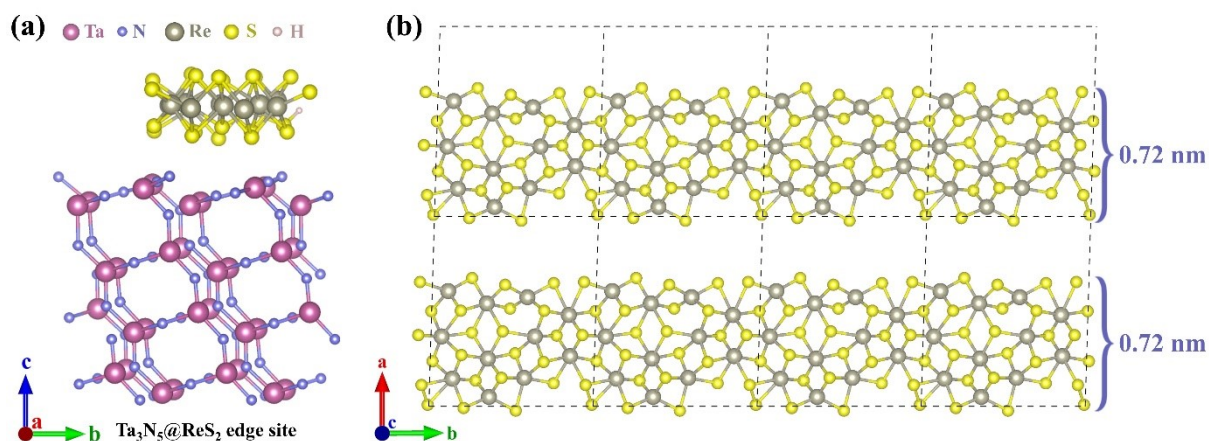


Fig. S11 The structures of Ta₃N₅ combined by incomplete ReS₂ with high-concentration V_{Re} (a) and ReS₂ sheet with edges (b).

According to the DOS in Fig. 9g(IV), it seems that there are a lot of interface states within the midgap, which would become the center of carrier recombination. With the loss of Re atoms, many unsaturated S atoms at the edge of ReS₂, implying that there are lots of V_{Re} defects at the edge of ReS₂. Accordingly, it could be concluded that a small number of V_{Re} would enhance the adsorption of H* with thus improved HER performance ($\Delta G_{\text{H}^*} = 0.06$ eV). However, too much V_{Re} would make the adsorption energy of H* be too high to desorb the H* with weakened HER performance ($\Delta G_{\text{H}^*} = -0.24$ eV). In the real experiment, the ReS₂ sheet is > 10 nm, which is too large for DFT calculations. Here, we built a ReS₂ sheet structural model with the size of 0.72 nm (see Fig. S11b), which is much smaller than that in real experiment to generate a much higher concentration of V_{Re} . If the concentration of V_{Re} are reduced by the edge passivation, the HER performance would get enhanced, implying that there might be an optimal defect concentration toward best HER performance.

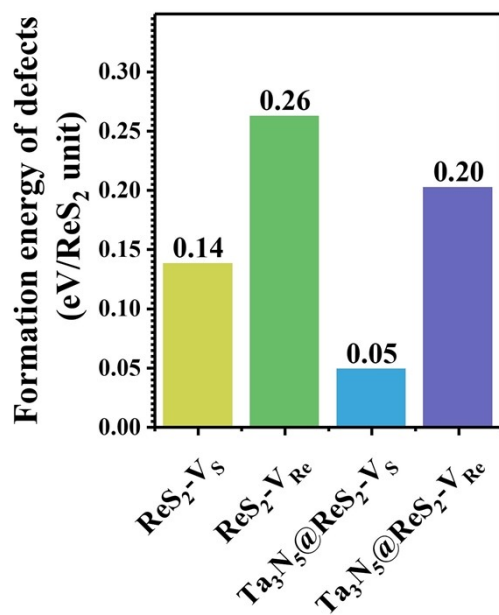


Fig. S12 The formation energies of the V_S and V_{Re} in sole ReS₂ surface and Ta₃N₅@ReS₂ heterostructure.

Table S1 The atomic ratio of the detected elements in EDX

element	Atom (%)
Ta	58.78
N	35.2
Re	2.1
S	3.92

Table S2 Comparison of activity for photocatalytic H₂ generation for some Ta₃N₅ based heterojunctions

Catalyst	Light source	Cocatalyst	Amount of H ₂ (μmol g ⁻¹ h ⁻¹)	AQE	Ref.
Ta ₃ N ₅ /ReS ₂ Uns	300W Xe lamp	/	739.4	0.102% at 420 nm	This work
Ta ₃ N ₅ /CdIn ₂ S ₄	300W Xe lamp	3 wt% Pt	122.6	/	1
Ta ₃ N ₅ /PANI	300W Xe lamp (λ>410nm)	/	72.6	/	2
MoS ₂ /Ta ₃ N ₅	300W Xe lamp	Pt	119.4	/	3
SrTaO ₂ N/Ta ₃ N ₅	300W Xe lamp (λ>420nm)	4 wt% Pt	19.07	/	4
MgO/Mg-Ta ₃ N ₅	300W Xe lamp (λ>400nm)	1 wt% Pt 2 wt% CoO _x	588	0.31% at 400 nm	5
Ta ₃ N ₅ /MoS ₂	300W Xe lamp (λ>420nm)	/	565	0.882% at 420 nm	6
Ta ₃ N ₅ Nanomeshes	Simulated sun light	1 wt% Pt	580	0.53% at 450 nm	7
Ta ₃ N ₅ /SrTaO ₂ N	300W Xe lamp (λ>420nm)	3 wt% Pt	77.31	/	8
ZnIn ₂ S ₄ /Ta ₃ N ₅	300W Xe lamp	3 wt% Pt	834.86	/	9
Ta ₃ N ₅ -WO _{2.72}	150 W Xe lamp	Pt	516	/	10

References

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